

PATENT 04020-P0005A WWW

THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants	Wolfgang Dettman, et al.		
Application No. 10/667,552	Filing Date: September 22, 2003		
Title of Application:	Photomask, In Particular Alternating Phase Shift Mask, With Compensation Structure		
Confirmation No. 9996	Art Unit: 2836		
Examiner			

Commissioner for Patents Post Office Box 1450 Alexandria, VA 22313-1450

Information Disclosure Statement by Applicants

As a means of complying with the duty of disclosure set forth in 37 CFR §1.56, Applicants list the following references (copies of the listed patents and papers enclosed).

U.S. Patent Documents						
Exam. Initials	Class/ Subclass.	Document No.	Date	Name		
A2	438/691	6,103,626	August 15, 2000	Kim		

Mailing Certificate: I hereby certify that this correspondence is today being deposited with the U.S. Postal Service as First Class Mail in an envelope addressed to: Commissioner of Patents and Trademarks; Post Office Box 1450; Alexandria, VA 22313-1450.

May 12, 2005

Rhonda S. Esaw

J. Course

8/02/05

Page 2 Serial No. 10/667,552 Information Disclosure Statement

Foreign Patent Documents						
Exam. Initials	Document No.	Date	Country			
M	DE 3703582 C1	April 7, 1988	Germany w/English abstract			
2	DE 19632845 A1	October 16, 1997	Germany w/English abstract			
#R	EP 0993030 A2	April 12, 2000	Europe			

The listed patents pertain in a general way to the subject matter of the application, but are not necessarily considered to be analogous prior art.

Respectfully submitted,

May 12, 2005

Wesley W. Whitmyer, Jr., Registration No. 33,558

Attorney for Applicants

ST.ONGE STEWARD JOHNSTON & REENS LLC

986 Bedford Street

Stamford, CT 06905-5619

203 324-6155

Date Considered

Examiner